ANNOUNCEMENTS

Chin and Murow Join Benesch

MARCH 20, 2020

Benesch is pleased to announce that Davis Chin and Daniel Murow have joined the firm.

Davis Chin joins Benesch's Chicago office as Of Counsel in Intellectual Property/3iP Practice Group. With an engineering background, Chin counsels a broad and diverse base of clients. With his support, Davis' clients are better positioned to preserve and protect new technologies, as well as use and manage their intellectual property thoughtfully. He graduated from The John Marshall Law School and the University of Iowa with a Bachelor of Science in Electrical Engineering.

Daniel Murow joins Benesch's Chicago office as an Associate in the Real Estate & Environmental Practice Group. Murow works with Real Estate Investment Trusts (REITs), institutional and individual investors and private equity funds, in the acquisition, development and financing of commercial properties across all asset classes. He also has extensive experience negotiating and drafting commercial leases for retail, office and industrial spaces ranging in size from 2,000 to 200,000 square feet. Murow graduated from the University of Nebraska College of Law, and from the University of Wisconsin School of Business.